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*Department of Chemistry and
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Tohoku University
Aoba, Sendai 980, JAPAN*

OSKAR NUYKEN
*Lehrstuhl für Makromolekulare
Stoffe
Technische Universität München
Lichtenbergstr 4
D-85747 Garching, GERMANY*

Distinguished Advisors

GEORGE B. BUTLER
*Department of Chemistry
University of Florida
Gainesville, FL-32601, USA*

MOTOWO TAKAYANAGI
*Department of Industrial Chemistry
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Fukuoka 813, JAPAN*

YUSUF YAĞCI
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